

MIRA

LMH

LMU

Resolution In high vacuum mode (SE) In low, medium vacuum mode (BSE/LVSTD)	1.5 nm at 30 kV 3.0 nm at 3 kV -	1.5 nm at 30 kV 3.0 nm at 3 kV < 2.5 nm at 30 kV 3.5 nm at 3 kV
Working vacuum Chamber – High vacuum mode Chamber – Low vacuum mode Gun vacuum	< 1 x 10 ⁻² Pa - < 1 x 10 ⁻⁶ Pa	< 1 x 10 ⁻² Pa 7 – 150 Pa < 1 x 10 ⁻⁶ Pa
Electron optics working modes	Resolution, Depth, Wide Field, Field, Rocking Beam	High Vacuum Resolution, Depth, Wide Field, Field, Rocking Beam
		Low Vacuum Resolution, Depth
Magnification	Continuous from 4x to 1,000,000x	13x - 1,000,000x
Accelerating voltage	500 V to 30 kV	
Electron gun	High brightness Schottky emitter	
Probe current	2 pA to 20 nA	
Scanning speed	From 200 ns to 10 ms per pixel adjustable in steps or continuously	
Focus window	Shape, size and position continuously adjustable	
Scanning features	Dynamic Focus, Point & Line Scan, 3D Beam	
Image size	Up to 8,192 x 8,192 pixels, adjustable separately for live images (in four steps) and for saved images (in 10 steps), for square and rectangular 4:3 or 2:1 image shapes.	
Microscope control	All microscope functions are PC controlled by means of the keyboard, the mouse and the trackball, via the program MiraTC, using the Windows™ platform	
Automatic procedures	The Probe Current and Spot Size continuously adjustable by unique In-Flight Beam Tracing™, Vacuum control, Gun Alignment, Centering of Resolution mode, Compensation for kV, Probe Current optimized for Spot Size, Spot Size optimized for Magnification, Scanning Speed, Brightness & Contrast, Focusing & Stigmator, Look up Table.	
Remote control	Via TCP / IP	
UPS	UPS 2kW is standard part of delivery scope	

Requirements

Installation requirements	Power 230 V/50 Hz or 120 V/60 Hz, 2200 VA No water cooling. Compressed dry nitrogen for venting: 150 – 500 kPa Compressed air for suspension: 450 – 600 kPa
Environmental requirements	Temperature of environment: 17 – 24 °C Relative humidity: max. 80 % Vibrations: Passive isolation: < 5 μm/s below 30 Hz; < 10 μm/s above 30 Hz; Active isolation (option): < 10 μm/s below 30 Hz; < 20 μm/s above 30 Hz Acoustic: < 60 dBC Background magnetic field: synchronous max. 3 x 10 ⁻⁷ T asynchronous max. 1 x 10 ⁻⁷ T System dimensions: 2.15 m x 1.25 m Room for installation: min. 3 m x 3 m

Software

	LMH	LMU
Measurement	●	●
Image Operation	●	●
Image Processing	●	●
3D Scanning	●	●
Hardness	●	●
Multi Image Calibrator	●	●
Object Area	●	●
Print Magnification	●	●
Switch-Off Timer	●	●
Tolerance	●	●
Morphology	○	○
Particle Analysis	○	○
Image Snapper	○	○
Sample Observer	○	○
Mouse Link	○	○

● standard, ○ option

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We are constantly improving the performance of our products, so all specifications are subject to change without notice.



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Distributor

MIRA_{LM}



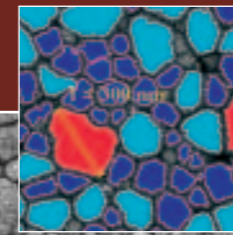
High Resolution Schottky FE SEM
with a Large Chamber and
a Motorized Compucentric Stage



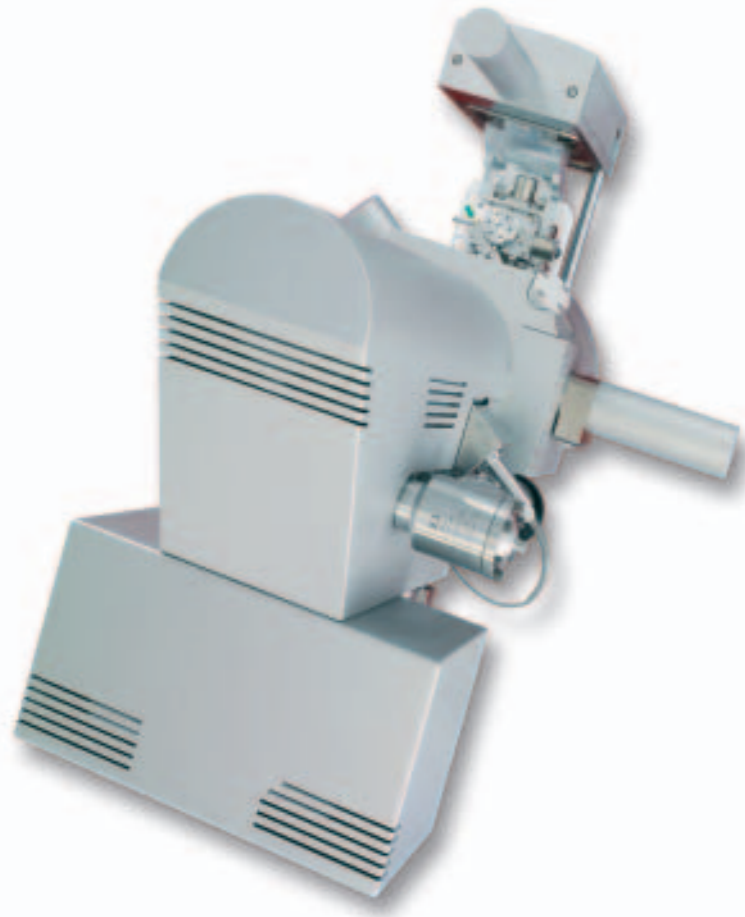
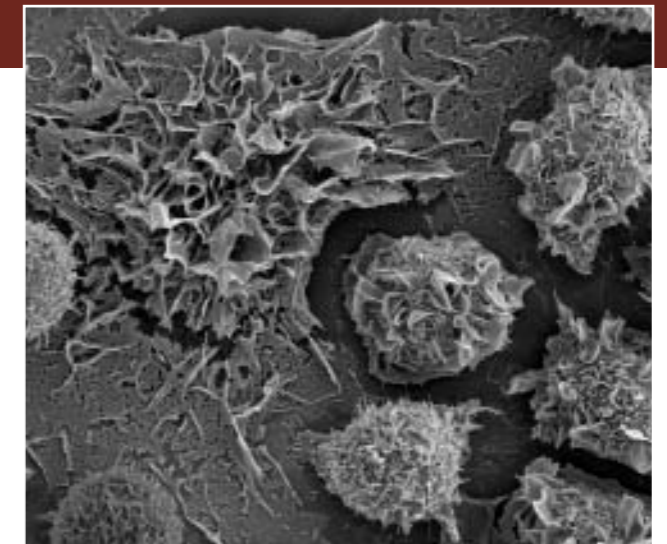
MIRA\ LM

The MIRA\ LM belongs to the Mira series of high performance scanning electron microscopes equipped with a Schottky field emission electron gun.

Application in material science: Morphology of nanocrystalline Zirconia



Application in microbiology: Cells grown on a glass slide



Features of the Mira FE SEM series

- A high brightness Schottky emitter for high-resolution/high-current/low-noise imaging
- A unique three-lens **Wide Field Optics™** design offering a variety of working and displaying modes embodying the Tescan proprietary Intermediate Lens for the beam aperture optimization
- Real time **In-Flight Beam Tracing™** for the performance and spot optimization integrating the well established Electron Optical Design software
- Fast imaging rate
- Fully automated microscope set-up including electron optics set-up and alignment
- Sophisticated software for SEM control, image acquisition, archiving, processing and analysis
- All network operations and built-in remote access/diagnostics come as a Tescan standard

Features of the LM chamber model

- 11 chamber interface ports with optimized geometry for EDX, WDX, EBSD
- High-throughput large-area automation, e.g. automated particle location and analyses
- A fully integrated active vibration isolation as an option
- 5 axes fully motorized compucentric stage with extended range of movements

MIRA\ LMH

A large chamber model with an extended motorized manipulator operates at a high vacuum for investigation of conductive samples with extraordinary imaging quality.

MIRA\ LMU

A variable pressure FE SEM that supplements all the advantages of the high vacuum model with extended facilities for low vacuum operations, allowing investigation of nonconductive specimens in their natural uncoated state.

Chamber LM

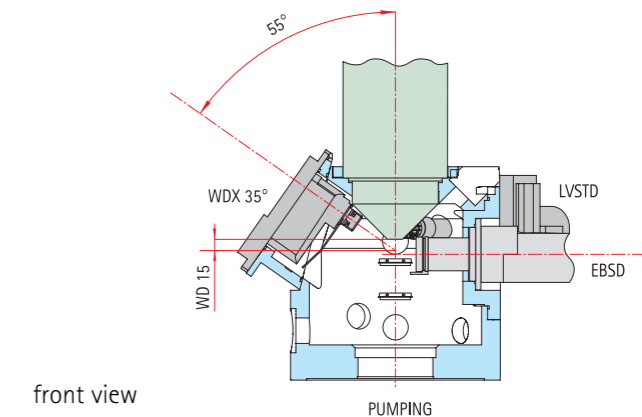
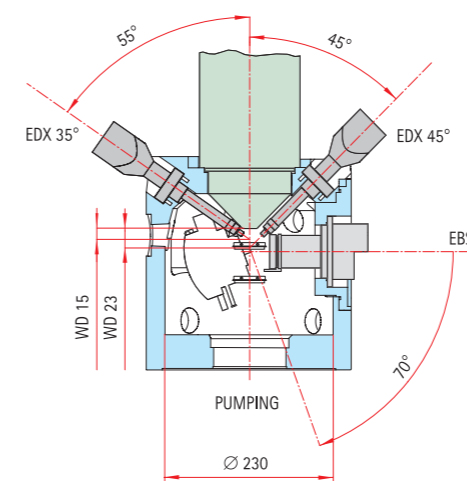
Internal diameter	Ø 230 mm
Door width	148 mm
Number of ports	11
Chamber suspension	pneumatic or optionally active vibration isolation

Specimen stage

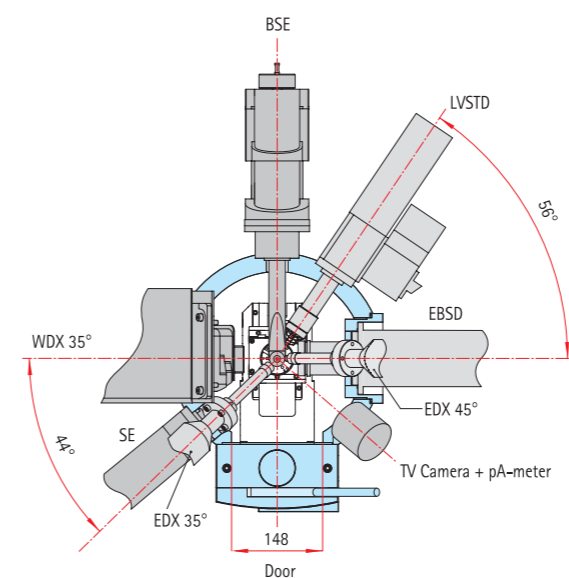
Type	compucentric
Movements	Fully motorized: X = 80 mm, Y = 60 mm, Z = 47 mm Rotation: 360° continuous Tilt: -75° to + 50° *
Specimen height	maximum 60 mm

* from WD 15 mm and for the eucentric height of the specimen

Ingenious port geometry allows the attaching of a large variety of detectors and makes MIRA\ LM microscope with an extraordinary analytical potential.



front view



top view

Detectors

	LMH	LMU
SE detector	●	●
Retractable BSE detector	●	●
LVSTD	-	○
TE detector	○	○
CL detector	○	○
EBIC	○	○
EDX*	○	○
WDX*	○	○
EBSD*	○	○

Accessories

	LMH	LMU
Probe current measurement	●	●
Touch alarm	●	●
Chamber view camera	●	●
Peltier cooling stage	○	○
Active vibration isolation	○	○
Magnetic field cancelling system	○	○
Beam blanker	○	○
Nanomanipulators *	○	○

* fully integrated third party products
● standard, ○ option